···	Supplemental	<u>.</u>			GD 12	28//		
TRANSMITTAL OI		Docket No. GS 174						
In Re Application Of:	Richard A. Blanchard et	a/. O 2 200	N 33					
Serial No.		Group Art	Unit					
10/039,284		2811						
Title: HIGH VOLTAGE	POWER MOSFET HA	AVING A VOLT	AGE SUSTAINING RI	EGION		,		
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of a national application other than a continued prosecution application under 37 CFR 1.53(d); within three months of the date of entry of the national stage as set forth in 37 CFR 1.491 in an international application; before the mailing of a first Office Action on the merits, or before the mailing of a first Office Action after the filing of a request for continued examination under 37 CFR 1.114.								
2.  The Information Disclosure Statement submitted herewith is being filed after the period specified in 37 CFR 1.97(b), provided that the Information Disclosure Statement is filed before the mailing date of a Final Action under 37 CFR 1.113, a Notice of Allowance under 37 CFR 1.311, or an Action that otherwise closes prosecution in the application, and is accompanied by one of:								
the statement specified in 37 CFR 1.97(e);								
	OR							
☐ the fee se	t forth in 37 CFR 1.17(	p).						
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TRANSMITTAL OF	INFORMATION DISCLOSU	RE STATEMENT	Docket No. GS 174
(U	nder 37 CFR 1.97(b) or 1.97(c)	<u> </u>	
In Re Application: R	Sichard A. Blanchard et al.	E VC59	
Serial No.	Filing Date	Examiner	Group Art Unit
10/039,284	12/31/01 PEN	DADEMARY Unassigned	4011
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Mayer Fortkort & Wil	•		35
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	Supplemental 55			ATTY DOCKET NO. GS 174		SERIAL NO.		039,284	
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EXAMINER		DOCUMENT NUMBER	DATE		NAME	CLASS	SUBCLASS	FILING DATE	•
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		2. May 22-25, 2000, pp. 69	)-72.					,	•
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		3.			Polycrystalline Silicon Resis		MAIL	ECE	•
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considered	considered. Include copy of this form with next communication to applicant.								